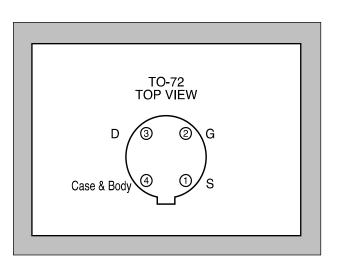
LINEAR SYSTEMS

Twenty-Five Years Of Quality Through Innovation

FEATURES						
DIRECT REPLACEMENT FOR INTERSIL 2N4351						
HIGH DRAIN CURRENT	$I_D = 20 \text{mA}$					
HIGH GAIN	g _{fs} = 1000µS					
ABSOLUTE MAXIMUM RATINGS ¹ @ 25 °C (unless otherwise stated)						
Maximum Temperatures						
Storage Temperature	-55 to +150 °C					
Operating Junction Temperature	-55 to +150 °C					
Maximum Power Dissipation, T _A =25°C						
Continuous Power Dissipation ³	350mW					
Maximum Current						
Drain to Source	20mA					
Maximum Voltages						
Drain to Body	25V					
Drain to Source	25V					
Gate to Source	±30V					

<u>2N4351</u>

N-CHANNEL MOSFET ENHANCEMENT MODE

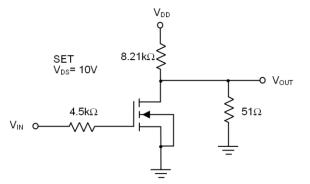


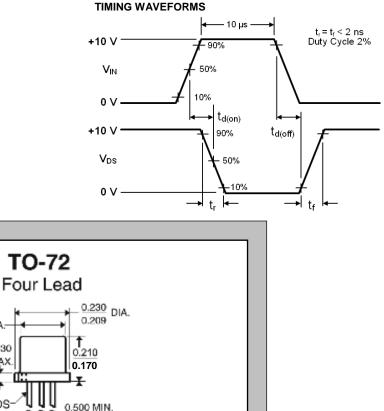
ELECTRICAL CHARACTERISTICS @ 25 °C (unless otherwise stated) (V_{SB} = 0V unless otherwise stated)

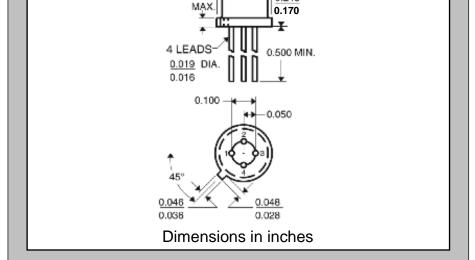
SYMBOL	CHARACTERISTIC	MIN	TYP	MAX	UNITS	CONDITIONS
BV _{DSS}	Drain to Source Breakdown Voltage	25				$I_D = 10 \mu A, V_{GS} = 0 V$
V _{DS(on)}	Drain to Source "On" Voltage			1	V	$I_D = 2mA$, $V_{GS} = 10V$
V _{GS(th)}	Gate to Source Threshold Voltage	1		5		$V_{DS} = 10V, I_D = 10\mu A$
I _{GSS}	Gate Leakage Current			10	pА	$V_{GS} = \pm 30V, V_{DS} = 0V$
I _{DSS}	Drain Leakage Current "Off"			10	nA	$V_{DS} = 10V, V_{GS} = 0V$
I _{D(on)}	Drain Current "On"	3			mA	$V_{GS}=10V,V_{DS}=10V$
g _{fs}	Forward Transconductance	1000			μS	$V_{DS} = 10V, I_D = 2mA, f = 1MHz$
r _{ds(on)}	Drain to Source "On" Resistance			300	Ω	$V_{GS} = 10V, I_{D} = 100uA, f = 1kHz$
C _{rss}	Reverse Transfer Capacitance ²			1.3		$V_{DS} = 0V, V_{GS} = 0V, f = 140 \text{kHz}$
C _{iss}	Input Capacitance ²			5.0	pF	$V_{DS} = 10V, V_{GS} = 0V, f = 140kHz$
C _{db}	Drain to Body Capacitance ²			5.0		$V_{DB} = 10V, f = 140kHz$

SYMBOL	CHARACTERISTIC	MAX	UNITS			
t _{d(on)}	Turn On Delay Time ²	45				
tr	Turn On Rise Time ²	65	ns			
t _{d(off)}	Turn Off Delay Time ²	60				
t _f	Turn Off Fall Time ²	100				

SWITCHING TEST CIRCUIT







1. Absolute maximum ratings are limiting values above which serviceability may be impaired.

0.195

0.175

DIA

0.030

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- 2. Not a production test. Guaranteed by design.
- 3. Derate 2.8 mW °C above 25 °C.

Linear Integrated Systems (LIS) is a 25-year-old, third-generation precision semiconductor company providing high-quality discrete components. Expertise brought to LIS is based on processes and products developed at Amelco, Union Carbide, Intersil and Micro Power Systems by company President John H. Hall. Hall, a protégé of Silicon Valley legend Dr. Jean Hoerni, was the director of IC Development at Union Carbide, co-founder and vice president of R&D at Intersil, and founder/president of Micro Power Systems.

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